(11) EP 0 834 253 A2

(12)

## **EUROPEAN PATENT APPLICATION**

(43) Date of publication: 08.04.1998 Bulletin 1998/15

(21) Application number: 97307369.5

(22) Date of filing: 22.09.1997

(51) Int CL<sup>6</sup>: **A01N 59/26**, A01N 59/16, A01N 59/06
// (A01N59/26, 47:30, 47:18, 47:04, 43:80, 43:78, 43:38), (A01N59/26, 47:30, 47:18, 47:04, 43:80, 43:78, 43:38), (A01N59/06, 47:30, 47:18, 47:04, 43:80, 43:78)

(84) Designated Contracting States:

AT BE CH DE DK ES FI FR GB GR IE IT LI LU MC NL PT SE

Designated Extension States: AL LT LV RO SI

(30) Priority: 04.10.1996 JP 264139/96

(71) Applicants:

Suganuma, Akio
 Urawa-shi, Saitama (JP)

Fujiwara, Hitoshi
 Sakura-shi, Chiba (JP)

(72) Inventor: Suganuma, Akio Urawa-shi, Saitama (JP)

(74) Representative: W.P. THOMPSON & CO. Eastcheap House Central Approach

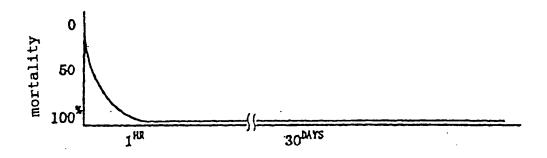
Letchworth, Hertfordshire SG6 3DS (GB)

## (54) Antimicrobial composition

(57) An antimicrobial composition comprises an inorganic metal antimicrobial agent, preferably a zirconium phosphate, a thiazole antimicrobial agent, preferably an isothiazolin-3-one compound, a haloalkylthio antimicrobial agent, preferably a haloalkylthiosulfimide compound, an imidazole antimicrobial agent, preferably a cyclic compound of benzimidazole, and an urea anti-

microbial agent, preferably a halophenyl derivative of dimethyl urea, as the essential compounds. The composition exhibits an excellent antimicrobial activity against various kinds of eumycetes, bacteria, actinomycetes, yeast and algae, is excellent in the quickness and persistency of the effect, and is extremely stable in itself.





0 834 2

#### Description

#### Field of Invention

The present invention relates to an antimicrobial composition or mixture, more specifically to a composition exhibiting excellent antimicrobial and antiseptic activities against various kinds of eumycetes, bacteria, actinomycetes, yeast and algae.

#### Background Art

10

15

20

25

30

Antiblastic and antifungal agents have recently been used for the purpose of attaining clean, comfortable and healthy surroundings or for the purpose of inhibiting resources and articles from being deteriorated by microorganisms, and therefore have held an extremely important position in various articles and fields, for example, textiles, timbers, building materials, leathers, adhesives, metal working lubricants, rubbers, plastics, films, paper-pulp industry, cooling water, high-technology industry, electrical machinery and apparatus, optical instruments, air conditioners, stockbreeding, fishery, agriculture, forestry, drugs, agricultural chemicals, water, cosmetics, toiletries, sanitary goods, preservation of food, hospitals, homes for the aged, public institutions, household goods, sporting goods, school supplies, and toys.

Further, such antiblastic and antifungal agents have recently been required not only to be applicable to various fields as described above but also to be efficacious against various kinds of microorganisms. For example, it is expected to develop an antiblastic and antifungal agent capable of inhibiting the growth of all of the 57 kinds of microorganism found in general architecture which were recognized by International Bio-Deterioration Symposium (Philadelphia, U. S.A.) in 1985 (at the sixth meeting held at Emanuel College, U.K.). Further, it is also expected to develop antiblastic, antifungal and antialgal agents capable of inhibiting the growth of not only eumycetes and bacteria but also algae.

In general, various inorganic metal compounds, organometallic compounds, organic compounds and natural products which have been used as antiblastic and antifungal agents each exhibit an inhibitory activity against several to ten or so kinds of microorganism. However, there has not been found any combination of two or more of these compounds which inhibits additional kinds of microorganism beyond their respective inhibitory powers. Further, there were even cases wherein a combination of two or more of the above compounds inhibited only fewer kinds of microorganism than the sum of kinds of microorganism which the compounds could inhibit separately.

Under these circumstances, in JP-A 8-92012, an antimicrobial composition was developed, which comprises a nitrile antimicrobial agent, a pyridine antimicrobial agent, a haloalkylthio antimicrobial agent, an organoiodine antimicrobial agent and a thiazole antimicrobial agent as the active ingredients and exhibits excellent antibacterial, antifungal and antialgal activities by virtue of the additivity and synergism of these agents. However, even this antimicrobial composition was not sufficiently satisfactory in its effect as an antimicrobial agent, such as the kinds of fungi which can be inhibited, quickness expression of antimicrobial power and persistency thereof, and other characteristics for antimicrobial agents, and in the stability of the composition in itself, and so on.

#### Disclosure of the Invention

40

The inventors of the present invention have intensively studied to solve the above problems and have found that an antimicrobial composition which can exhibit an excellent antimicrobial activity against various kinds of eumycetes, molds, bacteria, actinomycetes, yeast and algae, be excellent in quickness and persistency of the effect, and have high stability in itself can be obtained by blending together an inorganic metal antimicrobial agent, a thiazole antimicrobial agent, a haloalkylthio antimicrobial agent, an imidazole antimicrobial agent and a urea antimicrobial agent.

Specifically, the present invention relates to an antimicrobial composition characterized by comprising an inorganic metal antimicrobial agent, a thiazole antimicrobial agent, a haloalkylthio antimicrobial agent, an imidazole antimicrobial agent and a urea antimicrobial agent as the essential components.

The present invention provides an antifungal article or material comprising the composition defined above and a

50

55

The present invention provides a process for preventing the growth and activity of microorganisms by applying the composition as defined above to a locus where microorganisms would otherwise grow.

The present invention provides an antimicrobial composition comprising 1 to 96 % by weight of the inorganic metal antimicrobial agent, 1 to 96 % by weight of the thiazole antimicrobial agent, 1 to 96 % by weight of the haloalkylthio antimicrobial agent, 1 to 96 % by weight of the imidazole antimicrobial agent, and 1 to 96 % by weight of the urea antimicrobial agent.

The present invention provides an antimicrobial composition comprising 38 to 58 % by weight of the inorganic metal antimicrobial agent, 1 to 16 % by weight of the thiazole antimicrobial agent, 2 to 22 % by weight of the haloalkylthio antimicrobial agent, 3 to 23 % by weight of the imidazole antimicrobial agent, and 11 to 31 % by weight of the urea

antimicrobial agent.

5

10

15

20

25

35

40

45

50

The antimicrobial composition of the present invention can exhibit an excellent activity against a much larger number of kinds of microorganism such as eumycetes, bacteria, actinomycetes, and yeast than conventional antimicrobial compositions. Further, the composition can exhibit an excellent activity against algae for the first time.

The antimicrobial composition of the present invention can be excellent in persistency of the effect. It can continue to be effective for long periods, even after new bacteria have introduced themselves.

The antimicrobial composition of the present invention exhibits an excellent activity even if the concentration thereof is lower than that of conventional antimicrobial compositions.

The antimicrobial composition comprises plural kinds of antimicrobial agents so that a resistant bacteria may not be produced.

#### Modes for Carrying Out the Invention

The antimicrobial composition of the present invention will now be described in detail.

The inorganic metal antimicrobial agent to be used for the antimicrobial composition of the present invention includes zeolite antimicrobial agents, zirconium phosphate antimicrobial agents, titania antimicrobial agents, glass antimicrobial agents, silver salts complexes, and so on. Among these agents, zirconium phosphate antimicrobial agents are preferable, zirconium phosphate-silver being particularly preferably used.

The thiazole antimicrobial agent to be used for the composition of the present invention includes isothiazolin-3-one compounds and benzolhiazole compounds. Among these compounds, isothiazolin-3-one compounds are preferable.

The isothiazolin-3-one compounds include 1,2-benzisothiazolin-3-one, 2-(n-octyl)-4-isothiazolin-3-one, 5-chloro-2-methyl-4-isothiazolin-3-one, 2-methyl-4-isothiazolin-3-one, and 4,5-dichloro-2-cyclohexyl-4-isothiazolin-3-one. The benzothiazole compounds include 2-(4-thiocyanomethylthio)benzothiazole, 2-mercaptobenzothiazole sodium, and 2-mercaptobenzothiazole zinc. Among them, 1,2-benzisothiazolin-3-one is particularly preferable.

The haloalkylthio antimicrobial agent to be used for the composition of the present invention includes haloalkylthiophthalimide compounds, haloalkylthiosulfamide compounds, and haloalkylthiosulfimide compounds, among which haloalkylthiosulfimide compounds are preferable.

The haloalkylthiophthalimide compounds include N-fluorodichloromethylthiophthalimide and N-trichloromethylthiophthalimide; the haloalkylthiotetrahydrophthalimide compounds include N-1,1,2,2-tetrachloroethylthiotetrahydrophthalimide; the haloalkylthiosulfamide compounds include N-trichloromethylthio-N-(phenyl)methylsulfamide, N-trichloromethylthio-N-(4-chlorophenyl)methylsulfamide, N-(1-fluoro-1,1,2,2-tetrachloroethylthio)-N-(phenyl)methylsulfamide, and N-(1,1-difluoro-1,2,2-trichloroethylthio)-N-(phenyl)-methylsulfamide; and the haloalkylthiosulfimide compounds include N.N-dimethyl-N'-phenyl-N'-(fluorodichloromethylthio)sulfimide, N,N-dichlorofluoromethylthio-N'-phenylsulfimide, and N,N-dimethyl-N'-(p-tolyl)-N'-(fluorodichloromethylthio)sulfimide. Among these compounds, N,N-dimethyl-N'-phenyl-N'-(fluorodichloromethylthio)-sulfimide is particularly preferable.

The imidazole antimicrobial agent to be used for the composition of the present invention includes benzimidazole-carbamic acid compounds, sulfur-containing benzimidazole compounds, and cyclic compounds of benzimidazole, among which cyclic compounds of benzimidazole are preferable.

The benzimidazolecarbamic acid compounds include methyl 2-benzimidazolecarbamate, methyl 1-butylcar-bamoyl-2-benzimidazolecarbamate, methyl 6-benzoyl-2-benzimidazolecarbamate, and methyl 6-(2-thiophenecarbonyl)-2-benzimidazolecarbamate.

The sulfur-containing benzimidazole compounds include 2-thiocyanomethylthiobenzimidazole and 1-dimethylaminosulfonyl-2-cyano-4-bromo-6-trifluoromethylbenzimidazole.

The cyclic compounds of benzimidazole or benzimidazole compounds being substituted with another cyclic compound include 2-(4-thiazolyl)benzimidazole, 2-(2-chlorophenyl)-benzimidazole, 2-(1-(3,5-dimethylpyrazolyl))benzimidazole, and 2-(2-furyl)benzimidazole.

Among these compounds, 2-(4-thiazolyl)-benzimidazole is particularly preferable.

The urea antimicrobial agent to be used for the composition of the present invention includes halophenyl derivatives of dimethylurea, among which 3-(3,4-dichlorophenyl)-1,1-dimethylurea is preferable.

All of the above compounds are well-known ones and can readily be prepared by conventional processes. Further, many of them are commercially available, and such commercially available ones can also be used in the present invention.

The antimicrobial composition of the present invention can be prepared by mixing the above components together in suitable amounts, and the preferable amount of the composition to be added is 0.06 to 0.2% by weight based on the object of an article.

The form of the antimicrobial composition of the present invention is not particularly limited, but the composition may take various forms including water-based, powdery and solvent-based ones. That is, the above components are

converted into a desirable form by the use of optional components generally used for the form, and applied to various articles and in various fields, for example, textiles, timber, building materials, leathers, adhesives, metal working lubricants, rubbers, plastics, films, paper-pulp industry, cooling water, high-technology industry, electrical machinery and apparatus, optical instruments, air conditioners, stockbreeding, fishery, agriculture, forestry, drugs, agricultural chemicals, water, cosmetics, toiletries, sanitary goods, preservation of food, hospitals, homes for the aged, public institutions, household goods, sporting goods, school supplies, and toys.

The antimicrobial composition of the present invention is efficacious against various kinds of eumycetes, bacteria, actinomycetes, yeast and algae, specifically against not only 57 kinds of microorganism found in general architecture which were recognized by International Bio-Deterioration Symposium (Philadelphia, U.S.A.), but also other microorganisms. Further, the composition has advantageous effects, thought to be by virtue of the combination of inorganic and organic antimicrobial agents in that the antimicrobial spectrum can be extremely broad, that the composition can be extremely quick in its effect, and that the effect can persist for a long time.

The antimicrobial composition of the present invention can be extremely stable in itself, and therefore can have the following characteristics: The composition is free from lowering of activity or environmental pollution caused by the dissolution or volatilization of antimicrobial agents, because it comprises both an inorganic antimicrobial agent insoluble in aqueous media or organic solvents and organic antimicrobial agents insoluble in aqueous media; when the composition is incorporated into a plastic, film, sheet, cloth or synthetic paper, there occurs little change in the properties in heating for molding or processing, so that the resulting product suffers little from yellowing or lowering in the transparency; and when the composition is incorporated into a synthetic fiber, the resulting fiber is not affected by washing with an anionic detergent or the like.

Further, the antimicrobial composition of the present invention can be free from reductive discoloration which is one of the disadvantages of inorganic antimicrobial compositions, and is effective over a wide pH range. Further, the composition can be composed of chemicals registered as the existing chemical substances stipulated by the Ministry of International Trade and Industry and is therefore not problematic in safety.

#### Brief Explanation of the Drawing

Fig. 1 is a graph showing the mortality of Escherichia coli as observed in Example 2 wherein an antimicrobial composition of the present invention was used.

#### Examples

20

25

30

35

40

The present invention will now be described in detail by referring to the following Examples, though the present invention is not limited to them.

## Example 1

An antimicrobial composition was prepared by mixing together zirconium phosphate-silver as the inorganic metal antimicrobial agent, 1,2-benzisothiazolin-3-one as the thiazole antimicrobial agent, N,N-dimethyl-N'-phenyl-N'-(fluorodichloromethylthio)sulfimide as the haloalkylthio antimicrobial agent, 2-(4-thiazolyl)benzimidazole as the imidazole antimicrobial agent and 3-(3,4-dichlorophenyl)-1,1-dimethylurea as the urea antimicrobial agent in suitable amounts. An experiment was conducted to determine the minimum concentrations (ppm) of the antimicrobial composition at which the growth of the kinds of microorganism which will be listed (including 57 kinds of microorganism found in common buildings or living circumstances which were recognized by International Bio-Deterioration Symposium) was inhibited. More precisely, potato-agar media, Sabouraud's agar media and sucrose-agar media containing the above antimicrobial composition in various concentrations were prepared and test microorganisms of each kind prepared by single cell culture were planted on the media. The resulting media were kept in an incubator at 30°C and a relative humidity of 95% for 7 days. The lowest concentration of the antimicrobial composition at which the test microorganisms did not grow was taken as the minimal inhibitory concentration (MIC value). MIC is a concentration per the medium. The MIC values of the kinds of microorganism thus determined are as follows.

microorganisms having the MIC values of less than 1 ppm		
Tribonema sp.	Algae	
Anacystis nidulans	Algae	
Penicillium frequentance	Mold	
Penicillium citrinum	Mold	

55

(continued)

microorganisms having the MIC values of less than 1 ppm		
Fusarium semitectum	Mold	
Alternaria alternata	Mold	
Eurotium tonophilum	Mold	
Penicilium variable	Mold	
Penicilium Purpurogenum	Mold	
Aspergillus awamori	Mold	
Blastomyces dermatidis	Yeast	
Dactylium dendroides	Mold	
Medurella mycetomii	Mold	
Microsporum canis	Mold	
Blastomyces italicum	Yeast	
Rhizoctonia Violacea	Bacteria	
Cerespora beticola	Mold	
Cerespora musao	Mold	
Claviceps purpurea	Mold	
Colletotrichum trifolii	Mold	
Penicillium glaucum	Mold	
Pullularia pullulans	Mold	
Trichophyton mentagrophytes	Mold	
Botrytis cinerea	Mold	
Endothia paracitica	Bacteria	
Sclerotina sclerotiorum	Bacteria	
Venturia inaequalis	Bacteria	
Penicillium roqueforti	Mold	
Monilia laxa	Mold	
Monilia fructigana	Mold	
Lenzites trabea	Mold	
Ceratocystis sp.	Mold	
Diplodia viticola	Bacteria	
Neurospora sitophilia	Mold	
Oidium sp.	Mold	

microorganisms having the MIC values of at least 1	ppm and less than 10 ppm
Aspergillus niger	Mold
Aspergillus oryzae	Mold
Aspergillus flavus	Mold
Aspergillus versicolor	Mold
Aspergillus fumigatus	Mold
Aspergillus nidulans	Mold
Aspergillus glaucus	Mold
Aspergillus terreus	Mold
Aspergillus phoenicus	Mold
Aspergillus tamari	Mold
Aspergillus wentii	Mold
Aspergillus restrictus	Mold
Aspergillus ochraceous	Mold
Chaetomium clivaceum	Mold
Chaetomium globosum	Mold

(continued)

[	microorganisms having the MIC values of at least 1 ppm and	less than 10 ppm
	Cladosporium cladosporioides	Mold
5	Cladosporium sphaerospermum	Mold
	Cladosporium herbarum	Mold
	Bacillus corcus	Bacteria
	Vibreo perahaemolyticus	Bacteria
	Ascophyta pisi	Bacteria
10	Rhizoctonia solani	Bacteria
	Alternaria pisi	Mold
	Alternaria candidus	Mold
	Trichophyton gypseum	Mold
15	Trichophyton rubrum	Mold
	Penicillium luteum	Mold
	Penicillium expansum	Mold
	Phomosis citri	Mold
	Diplodia natalensis	Mold
20	Fusarium oxysporum	Mold
	Penicillium chrysogenum	Mold
	Venticillium albo-atrum	Mold
	Ustilago zeae	Mold
25	Penicillium citreo-viride	Mold
	Oscillatoria aurea	Algae
	Stichococcus bacillavis	Mold
	Pestalotia neglecta	Mold
	Fusarium roseum	Mold
30	Alternaria brassicicola	Mold
	Geotrichum candidum	Mold
,	Geotrichum lactus	Mold
·	Gliocladium vireus	Mold
35	Phacidipycnus funfuracea	Mold
	Phymatotricum omnivorum	Mold
	Sclerotina fructincola	Mold
	Aureobasidium pullulans	Mold
	Fusarium solani	Mold
40	Penicillium notatum	Mold
	Penicillium rubrum	Mold
	Trichothecium roseum	Mold
	Lenzites trabae	Mold
45	Monilia nigra	Mold
•	Microsporum audouini	Mold
	Penicillium cyclopium	Mold
	Colletotrichum lindemuthianum	Mold
	Ceratocystis ulmi	Mold
50	Phoma terrestrius	Mold
	Candida albicans	Yeast
	Microsporum gypseum	Mold
	Penicillium oxalicum	Mold
55	Penicillium spinulosum	Mold
==	Penicillium funiculosum	Mold
	Penicillium digitatum	Mold

# (continued)

microorganisms having the MIC values of at least 1 ppm and less than 10 ppm		
Fusarium roseum	Mold	
Schizothrix sp.	Algae	
Hormidium sp.	Algae	
Ulothlichaceae sp.	Algac	

10	microorganisms having the MIC values of at least	10 ppm and less than 20 ppm
	Candida acutus	Yeast
	Phaffia rhodozyma	Bacteria
	Sporobolomyces roseus	Yeast
15	Pichia anomala	Bacteria
	Pichia membranaefaciens	Bacteria
	Zygosaccharomyces rouxii	Yeast
	Zygosaccharomyces bailii	Yeast
20	Rhodotorula gulinis	Mold
	Rhodotorula lactosa	Mold
	Streptococcus lactis	Bacteria
•	Aerobacter aerogenes	Mold
	Clostridium acetobutylicum	Mold
25	Clostridium sporogenes	Mold
	Campylabacter jejuni	Bacteria
	Cryptococcus lutealus	Mold
	Schizosaccharomyces pombe	Yeast
30	Saccharomycodes ludwigii	Bacteria
	Saccharomycodes pasteurianus	Mold
	Pichia membranaefaciens	Mold
	Debaryamyces hansenii	Bacteria
-	Hansemula anomala	Bacteria
95	Kloeckera apiculata	Bacteria
	Candida utilis	Yeast
	Aspergillus luchensis	· Mold
	Penicillium islandicum	Mold
10	Trichophyton ajelloi	Mold
	Cryptococcus neoformans	Mold
	Helminthosporium sp.	Mold
	Rhizopus nigricans	Mold
	Rhizopus oryzae	Mold
15	Hormoderdrum pedrosoi	Mold
	Mucor racemosus	Mold
	Sporotrichum schenckii	Mold
	Stachybotrys sp.	Mold
50	Chlorella vulgaires	Algae
	Epicoccum purpurascens	Mold
	Pestalotia adusta	Mold
	Penicillium nigricans	Mold
	Penicillium lilacinum	Mold
55	Phoma glomerata	Mold
	Paecilomyces lilacinus	Yeast
	Cladosporium resinae	Mold

(continued)

(35)	
microorganisms having the MIC values of at least	st 10 ppm and less than 20 pp
Gluconobacter suboxydans	Bacteria
Serratia marcesens	Bacteria
Micrococcus glatamicus	Bacteria
Streptococcus faccalis	Bacteria
Streptococcus thermophilus	Bacteria
Podiococcus soyae	Bacteria
Podiococcus acidilactici	Bacteria
Lactobacillus acidophilus	Bacteria
Lactobacillus plantarum	Bacteria
Autotrophic bacteria	Bacteria
Streptomyces griseus	Actinomycetes
Streptomyces aureofaciens	Actinomycetes
Streptomyces kasugaensis	Actinomycetes
Acuremonium charticola	Mold
Chlorococcum sp.	Algae
Oscilatoria sp.	Algae

microorganisms having the MIC values of at least 20 ppm and less than 30 ppm		
Anabana sp.	Algae	
Cladophora glomerata	Algae	
Ankistrodemus angustus	- Algae	
Chlamydomonas reinhardii	Algae	
Trentephohlia odarata	Algae	
Alternaria tenuis	Mold	
Cryptococcus albidas	Mold	
Paecilomyces variotti	Yeast	
Fusarium proliferatum	Mold	
Anacystis sp.	Algae	
Chlorella emersonii	Algae	

microorganisms having the MIC values of at least 30 ppm and less than 50 ppm		
Rhizopus storonifer	Mold	
Escherichia coli	Bacteria	
Staphylococcus aureus	Bacteria	
Pseudomonas aeruginosa	Bacteria	
Salmonella typhimurium	Bacteria	
Legionella pneamophila	Bacteria	
Leptospira interrogans	Bacteria	
Rickettsia rickettsii	Bacteria	
Mycobacterium tubercolosis	Bacteria	
Proteus mirabilis	Bacteria	
Proteus vulgaris	Bacteria	
Staphylococcus epidermidis	Bacteria	
Micrococcus candidus	Bacteria	
Bacillus mycoides	Bacteria	
Pseudomonas fluresceus	Bacteria	

# (continued)

microorganisms having the MIC values of at least 30 pp	
Bacillus subtillis	Bacteria
Bacillus megaterium	Bacteria
Streptoverticillum reticulum	Bacteria
Nigrospora oryazac	Mold
Trichoderma koningii	Mold
Trichoderma T-1	Mold
Trichoderma viride	Mold
Fusarium moniliforme	Mold
Myrothecium verrucaria	Mold
Streptococcus faecalis	Bacteria
Salmonella enteritidis	Bacteria
Pseudomonas flourescens	Bacteria
Salmonella enterrica	Bacteria
Salmonella arizonae	Bacteria
Salmonella paratyphi	Bacteria
Salmonella choleraesuis	Bacteria
Campylobacter fetus	Bacteria
Streptococcus agalactiae	Bacteria
Serratia marcesceus	Bacteria
Serratia liguefaciens	Bactoria
Klebsiella oxytoca	Bacteria
Clostridium perfringens	Bacteria
Clostridium diffcile	Bacteria
Bacillus anthracis	Bacteria
Vibrio fluvialis	Bacteria
Vibrio mimicus	Bacteria
Vibrio ulnificus	Bacteria
Vibrio omma	Bacteria
Mucor mucedo	Mold ·
Mucor pusillus	Mold
Rhyzopus delemar	Mold
Absidia glauca	Mold
Pleurococcus sp.	Algae
Scytonema hofmannii	Aigae

microorganisms having the MIC values of at least 50	ppm and less than 70 ppm
Wallemia sebi	Mold
Saccharomyces cerevisiae	Yeast
Klebsiella pneumoniae	Bacteria
Bacillus punctatum	Bacteria
Bacterium vulgaro	Bacteria
Bacterium pyocyaneum	Bacteria
Thio bacilus sp.	Bacteria
Fusarium nivale	Mold
Fusarium avenaceum	Mold
Fusarium acuminatum	· Mold
Pythium vanterpoolii	Bacteria
Phyrarium cinereum	Bacteria

#### (continued)

microorganisms having the MIC values of at least 50 ppm and less than 70 ppm		
Aster yellows	Bacteria	
Sugeran mosaic	Bacteria	
Corticium fuciforme	Bacteria	
Lepiota criststa	Bacteria	
Lepiota castanae	Bacteria	
Mesotaenium	Algae	
Zygogonium	Algae	
Trentephohlia aurea	Algae	

#### Example 2

5

10

15

25

30

35

40

45

50

55

The mortality of the antimicrobial composition used in Example 1 was determined by the use of Escherichia coli. Specifically, 4.6 x 10<sup>6</sup> of Escherichia coli was prepared and transplanted to a test piece made of polypropylene containing 0.1% by weight of the antimicrobial composition described above, placed on a medium for the culture of Escherichia coli. The resulting system was cultured in a circulator (temp: 37°C, humidity: 95%) to determine the mortality. The results are shown in Fig. 1. It can be understood from the results shown in Fig. 1 that the antimicrobial composition of the present invention can destroy most (at least 99 %) of Escherichia coli only in one hour and the effect can persist for 40 days or more without any change.

#### Example 3

The antiblastic test of the antimicrobial composition of the present invention used in Example 1 was determined by the use of Staphylococcus aureus as the test microorganism. Specifically, 1.1 x 10<sup>6</sup> of Staphylococcus aureus was prepared and transplanted to a test sample placed on a medium for the culture of Pseudomonas aeruginosa, and the resulting system was cultured in a circulator (temp: 37°C, humidity: 95%). The viable count was determined after 1, 24 and 48 hours and 30 days. The test samples used were test piece (Invention) produced by injection-molding a polypropylene containing 0.1% by weight of the antimicrobial composition used in Example 1 and test piece produced by injection-molding a polypropylene, being free from the antimicrobial composition. The results are given in Table 1.

·	Viable count after Viable count after 24 one hour hours		Viable count after 48 hours	Viable count after 30 days	
Compnfree piece	3.7×10 <sup>7</sup>	4.1×10 <sup>8</sup>	5.0×10 <sup>8</sup>	5.5×10 <sup>8</sup>	
Invention	4.3×10 <sup>3</sup>	3.6×10 <sup>3</sup>	2.8×10 <sup>3</sup>	1.1×10 <sup>2</sup>	

#### Example 4

The antimicrobial composition of the present invention used in Example 1 was examined for antifungal fungiagainst. Specifically, a test solution containing 10<sup>6</sup> of 15 kinds of eumycetes was prepared and sprayed on a test sample placed on a Sabouraud's agar media (wet method). The resulting system was cultured in a circulator (temp: 28°C±5°C, humidity: 90%±10%) to determine the fungal growth. The test samples used were test piece (Invention) produced by injection-molding a polypropylene containing 0.1% by weight of the antimicrobial composition used in Example 1 and test piece produced by injection-molding a polypropylene, being free from the antimicrobial composition. The results of exsistence of the fungal growth observed after 10, 20 and 40 days are given in Table 2, wherein the symbol "+" means a case wherein fungi grew, and the symbol "-" a case wherein fungi did not grow.

Table 2

Table 2				
	after 10 days	after 20 days	after 40 days	
Compnfree piece	+	+	+	
Invention	-	•	-	

#### Example 5

5

10

15

20

25

30

35

40

45

50

## 1)Preparation of an antimicrobial composition

An antimicrobial composition was prepared by mixing the five kinds of antimicrobial agent described in the following Table 3.

Table 3

kind of antimicrobial agent	name of compound	content (wt.%)
inorganic metal	zirconium phosphate-silver	48
thiazole	1,2-benzisothiazolin-3-one	6
haloalkylthio	N,N-dimethyl-N'-phenyl-N'-(fluorodichloromethylthio)-sulfimide	12
imidazole	2-(4-thiazolyl)benzimidazole	13
urea	3-(3,4-dichlorophenyl)-1,1-dimethylurea	21

#### 2)Preparation of a test solution

The above antimicrobial composition was suspended in a sterilized saline solution in an amount of 1%. It was used as the test solution. Another sterilized saline solution, being free from the antimicrobial composition, was used as a control.

#### 3)Preparation of a solution of fungi

Staphylococcus aureus IID 1677 resistance to methicillin (MRSA) was used as the test fungi. MRSA was shaked and cultured at 35°C in 20 hours on an NB medium prepared by adding 0.2% of meat extract to a broth medium, produced by Eiken Kagaku. The cultured medium was diluted 200 times by a sterilized phosphate-buffered saline solution. It was used as the solution of fungi.

## 4) Antimicrobial activity experiment

1 ml of the solution of fungi was added to 100 ml of the test solution and the control, and mixed. The resulting system was allowed to store at 25 °C for 24 hours. The number of living strains was determined by drawing two lines in parallel of the bacteria with a platinum needle at 35°C for 2days using SCDLPA agar media produced by Nihon Seiyaku. The results are shown in Table 4. It was confirmed that, with 1 ml of the test solution diluted as ten times, the number of living strains could be determined by a preliminary test.

Table 4

fungus		the living number (/ml)		
		starting time*	after 24 hours	
MRSA	test solution control	1.2 x 10 <sup>5</sup> 1.2 x 10 <sup>5</sup>	<10 3.0 x 10 <sup>3</sup>	

<sup>&</sup>quot;<10" means no detection.

## Example 6

1)Preparation of an antimicrobial composition

The antimicrobial composition prepared in Example 5 was used.

## 55 2)Preparation of a test solution

The test solution was prepared in the same manner as in Example 5, except that a sterilized purified water was used instead of a sterilized saline solution.

<sup>\*:</sup>The number of living strains (viable count) was determined in the control just after addition of the solution of fungi. This is the value of the starting time.

## 3)Preparation of a solution of fungi

Escherichia coli ATCC 43895 (colibacilli, serotype O157:H7, species to produce Vero toxin I, II) was used as the test fungi. The solution of fungi was prepared in the same manner as in Example 5, except that a sterilized phosphate buffer was used instead of a sterilized phosphate-buffered saline solution.

#### 4)Antimicrobial activity experiment

The antimicrobial activity experiment was carried out in the same manner as in Example 5. The results are shown in Table 5. It was confirmed that, with 1 ml of the test solution diluted as ten times, the number of living strains could be determined by a preliminary test.

Table 5

fungus		the living nu	mber (/ml)
		starting time*	after 24 hours
colibacilli	test	3.0 x 10 <sup>5</sup>	<10
O157:H7	solution		
	control	3.0 x 10 <sup>5</sup>	3.4 x 10 <sup>5</sup>

<sup>&</sup>quot;<10" means no detection.

#### Claims

25

5

10

15

20

35

40

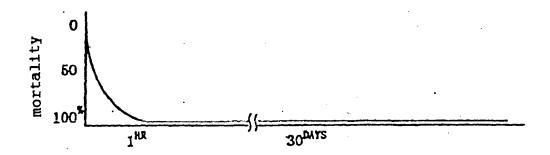
- 1. An antimicrobial composition comprising an inorganic metal antimicrobial agent, a thiazole antimicrobial agent, a haloalkylthio antimicrobial agent, an imidazole antimicrobial agent, and an urea antimicrobial agent.
- 2. A composition as claimed in claim 1, wherein the inorganic metal antimicrobial agent is selected from zeolite antimicrobial agents, zirconium phosphate antimicrobial agents, titania antimicrobial agents, glass antimicrobial agents, and silver salts complexes.
  - A composition as claimed in claim 2, wherein the inorganic metal antimicrobial agent is a zirconium phosphate antimicrobial agent.
  - 4. A composition as claimed in any of claims 1 to 3, wherein the thiazole antimicrobial agent is selected from isothiazolin-3-one compounds and benzothiazole compounds.
  - 5. A composition as claimed in claim 4, wherein the thiazole antimicrobial agent is an isothiazolin-3-one compound.
  - 6. A composition as claimed in any of claims 1 to 5, wherein the haloalkylthio antimicrobial agent is selected from haloalkylthiophthalimide compounds, haloalkylthiotetrahydrophthalimide compounds, haloalkylthiosulfamide compounds, and haloalkylthiosulfimide compounds.
- A composition as claimed in claim 6, wherein the haloalkylthio antimicrobial agent is a haloalkylthiosulfimide compound.
  - A composition as claimed in any of claims 1 to 7, wherein the imidazole antimicrobial agent is selected from benzimidazolecarbamic acid compounds, sulfur-containing benzimidazole compounds, and cyclic compounds of benzimidazole.
  - 9. A composition as claimed in claim 8, wherein the imidazole antimicrobial agent is a cyclic compound of benzimi-dazole.
- 10. A composition as claimed in any of claims 1 to 9, wherein the urea antimicrobial agent is a halophenyl derivative of dimethylurea.
  - 11. A composition as claimed in claim 1, wherein the inorganic metal antimicrobial agent, the thiazole antimicrobial

<sup>\*:</sup>The number of living strains was determined in the control just after addition of the solution of fungi. This is the value of the starting time.

agent, the haloalkylthio antimicrobial agent, the imidazole antimicrobial agent, and the urea antimicrobial agent are a zirconium phosphate antimicrobial agent, an isothiazolin-3-one compound, a haloalkylthiosulfimide compound, a cyclic compound of benzimidazole, and a halophenyl derivative of dimethylurea, respectively.

- 12. A composition as claimed in any of claims 1 to 11, comprising 1 to 96 % by weight of the inorganic metal antimicrobial agent, 1 to 96 % by weight of the thiazole antimicrobial agent, 1 to 96 % by weight of the imidazole antimicrobial agent, and 1 to 96 % by weight of the urea antimicrobial agent.
- 13. A composition as claimed in claim 12, comprising 38 to 58 % by weight of the inorganic metal antimicrobial agent, 1 to 16 % by weight of the thiazole antimicrobial agent, 2 to 22 % by weight of the haloalkylthio antimicrobial agent, 3 to 23 % by weight of the imidazole antimicrobial agent, and 11 to 31 % by weight of the urea antimicrobial agent.
  - 14. An antifungal article comprising a composition as claimed in any of claims 1 to 13 and a carrier.
  - 15. A process for preventing the growth and activity of microorganisms by applying the composition as claimed in any of claims 1 to 13 to a locus where microorganisms would otherwise grow.





# Europäisches Patentamt European Patent Office Office européen des brevets

EP 0 834 253 A3

(12)

#### **EUROPEAN PATENT APPLICATION**

- (88) Date of publication A3: 16.09.1998 Bulletin 1998/38
- (43) Date of publication A2:08.04.1998 Bulletin 1998/15
- (21) Application number: 97307369.5
- (22) Date of filing: 22.09.1997

- (51) Int CI.6: A01N 59/26, A01N 59/16, A01N 59/06, A01N 47/30, A01N 47/18, A01N 47/04, A01N 43/80, A01N 43/78, A01N 43/38 // (A01N59/26, 47:30, 47:18, 47:04, 43:80, 43:78, 43:38), (A01N59/26, 47:30, 47:18, 47:04, 43:80, 43:78, 43:38), (A01N59/06, 47:30, 47:18, 47:04, 43:80, 43:78)
- (84) Designated Contracting States:

  AT BE CH DE DK ES FI FR GB GR IE IT LI LU MC

  NL PT SE

  Designated Extension States:
- (30) Priority: 04.10.1996 JP 264139/96
- (71) Applicants:
  - Suganuma, Akio
     Urawa-shi, Saitama (JP)

AL LT LV RO SI

 Fujiwara, Hitoshi Sakura-shi, Chiba (JP)

(11)

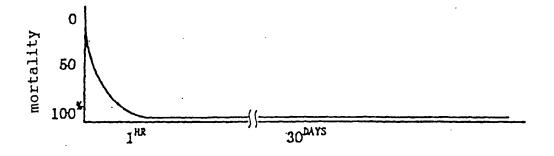
- (72) Inventor: Suganuma, Akio Urawa-shi, Saitama (JP)
- (74) Representative: W.P. THOMPSON & CO. Eastcheap House Central Approach Letchworth, Hertfordshire SG6 3DS (GB)

#### (54) Antimicrobial composition

(57) An antimicrobial composition comprises an inorganic metal antimicrobial agent, preferably a zirconium phosphate, a thiazole antimicrobial agent, preferably an isothiazolin-3-one compound, a haloalkylthio antimicrobial agent, preferably a haloalkylthiosulfimide compound, an imidazole antimicrobial agent, preferably a cyclic compound of benzimidazole, and an urea anti-

microbial agent, preferably a halophenyl derivative of dimethyl urea, as the essential compounds. The composition exhibits an excellent antimicrobial activity against various kinds of eumycetes, bacteria, actinomycetes, yeast and algae, is excellent in the quickness and persistency of the effect, and is extremely stable in itself.





Printed by Jouve, 75001 PARIS (FR)



## **EUROPEAN SEARCH REPORT**

Application Number EP 97 30 7369

Sategory :	Citation of document with in- of relevant passa		Relevant to claim	CLASSIFICATION OF THE APPLICATION (Int.CL6)
Υ	DATABASE WPI Section Ch, Week 954 Derwent Publications Class A14, AN 95-309 XP002071558 & JP 07 207 525 A (Material Report Process * abstract *	s Ltd., London, GB; 9593	1-15	A01N59/26 A01N59/16 A01N59/06 A01N47/30 A01N47/18 A01N47/04 A01N43/80 A01N43/78
Y	GB 1 389 940 A (ROHF see: page 1, col. 2 col. 1, lines 16 - 2	 M & HAAS) 9 April 1975 , lines 59 - 64; page 2 22.	1-15	A01N43/78 A01N43/38 //(A01N59/26, 47:30,47:18, 47:04,43:80,
Y	EP 0 732 052 A (HAG: JAPAN ELECTRONIC M/ September 1996 * page 5, line 34-5	ATERIALS (JP)) 18	1-15	43:78,43:38), (A01N59/26, 47:30)
Y	EP 0 680 695 A (ROHI 1995 * example 3; tables	M & HAAS) 8 November	1-15	
Y	US 5 185 357 A (INU 1993 * the whole documen	I KEIICHIRO) 9 February	1-15	TECHNICAL FIELDS SEARCHED (Int.Cl.6)
I		-/		,
		•		
	The present search report has	been drawn up for all claims		
	Place of search	Date of completion of the search	1	Examiner
}	MUNICH	15 July 1998	K1	aver, J
X pa Y pa do A tes	CATEGORY OF CITED DOCUMENTS inflicularly relevant if taken alone inflicularly relevant if combined with anoticument of the same category shhological background no-written disclosure	E : earlier patent do after the filling da ther D document cited t L : document cited t	le underlying the cument, but put ite in the applicatio for other reason	e invention blished on or



# EUROPEAN SEARCH REPORT

Application Number

EP 97 30 7369

Category	Citation of document with indi- of relevant passag			Relevant to claim	CLASSIFICATION APPLICATION	
Y	CHEMICAL ABSTRACTS, No. 6 January 1992 Columbus, Ohio, US; abstract no. 2297q, K. KOTANI & T. TERAMA incorporated synergis algicidal composition 2-(4-thiazolyl)benzim 2-octyl-4-isothiazoli page 2292; XP002071557	AE: "Polymer stic fungicidal ns containing nidazole and		-15		
Y	* abstract * & JP 03 167 103 A (St 19 July 1991	MITOMO CHEMICA	_ CO.) 1	-15		
Y	EP 0 390 394 A (ICI F * page 7, line 15-26;		1990 1	-15		
Υ	GB 1 542 829 A (BAYER * the whole document		1979 1	-15	TECHNICAL F	.c. 00
Y	US 4 008 351 A (INOUE February 1977 * the whole document		15	-15	SEARCHED	(Int.Cl.6)
	The present search report has been Place of search MUNICH	en drawn up for all claims Date of completion of 15 July 19		Klav	Examiner /er, J	
X : parti Y : parti docu A : tech O : non-	ATEGORY OF CITED DOCUMENTS cularly relevant if taken alone cularly relevant if combined with another intent of the same category notogical background written disclosure mediate document	E : earl atter D : doc L : doc & : mer	ny or annapte under patent document atted in the time date ument atted for our of the same unent atted for our of the same attentions.	ent, but publis e application ther reasons	no bed	

EPO FORM 1563 63.82 (P34C61)

THIS PAGE BLANK (USPTO)